



APPLN. OF:

FOTLAND et al.

**SERIAL NO.:** 

09/299,388

FILED:

April 27, 1999

FOR:

METHOD FOR DEPOSITING PARTICLES ONTO

**GROUP:** 

1619

**EXAMINER:** 

FRANK I. CHOI

**DOCKET: MICRODOSE 99.01 CON** 

SEP 1 9 2002

**Assistant Commissioner for Patents** Washington, D.C. 20231

## AMENDMENT E

Dear Sir:

This Amendment is being filed in response to the Official Action mailed June 14, 2002.

Please amend the Application as follows:

## **IN THE CLAIMS:**

Please amend claims 1, 32-34, 48, 52-57, 60, 63, 64, 66, 67 and 69-71 to read as follows:

1. (Thrice Amended) A method for depositing particles onto a dielectric substrate comprising the steps of forming an aerosol of said particles in a first region; transporting the resulting aerosol to a second region, and applying a charge on said aerosol particles in said second region, positioning said charged aerosol particles with essentially a zero velocity in a deposition zone located in said second region proximate to said dielectric substrate, and applying an alternating electric field formed in said deposition zone between a first electrode positioned in said second region and a second electrode positioned underlying and in contact with said dielectric substrate whereby to drive said charged particles from the aerosol and deposit said



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